

LAM Research TCP9600 Metal Etch 200mm Configuration SN 4330

LAM Research TCP9600 Etch SN 4330 Location warehouse Nijmegen



Stand-Alone/Bulkhead System (dual monitor upgrade)

SW: Envision 1.6.1-012

Configured for 200mm Wafers

Hine 38A open cassette Send/Receive indexers

Mainframe: TCP9600

On-Board AC Dist.

On-Board RF Generators: (3) Onboard AE RFG 1250

SECS Interface

Main Process Module (PM1): TCP 9600

Wafer Clamp: ESC w/He Cooling

Electrode Gap: Fixed gap

8" TCP Coil Turbo Missing

Gate Valve: VAT 65 Pendulum 200mm 769-098282-012

Heated Pump Stack & Manifold

Endpoint Detection: Dual Photo diode

Endpoint Wavelength(s): 703nm and 261.8nm

PM2: DSQ Stripper

Hinged DSQ

Orbitally Welded Gas Box Backside Helium Cooling Gas Line 1 2 4 5 6 7 8

Gas Flow (sccm) MFC Mfgr. MFC Model

Cl2	100	Unit 1660
BCL3	100	Unit 1660
CH4	10	Unit 1660
N2	10	Unit 1660
O2	200	Unit 1660
02	500	Unit 1660

H20 500 Tylan VC-4900VRH

Power Requirements: 208V, 80A, 3-Phase, Freq 50/60Hz

LAM Research TCP9600 Etch SN 4330



Location warehouse Nijmegen condition Refurbished



www.Solutions-on-Silicon.com

Solutions on Silicon BV

SOS GROUP

Your service partner for LAM Research Equipment

Equipment Support

PM, CM, Trouble shooting, Upgrading, Training and Onsite Service Contracts

Process Support

Process design, Improvement, Fab-to-Fab Transfer and Integration

Refurbishment

From custom to complete refurbishment

Relocation

Auditing, Fingerprinting, Decommissioning, Installation, Acceptance

Materials

Supplier of first class second source materials

